

IPW



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Schang-Jing Hon :  
Serial No. : 10/781,769 : Art Unit #2818  
Filed : 20 February 2004 : Examiner: D. Nhu  
Title : GALLIUM NITRIDE VERTICAL LIGHT  
EMITTING DIODE STRUCTURE AND  
METHOD OF SEPARATING A SUBSTRATE  
AND A THIN FILM IN THE STRUCTURE

RESPONSE TO RESTRICTION REQUIREMENT  
AND AMENDMENT

Mail Stop NO FEE  
Honorable Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Applicant, by the undersigned attorney hereby responds to the outstanding  
Official Action dated 8 April 2005 which is a Restriction Requirement. Please  
amend the above-referenced patent application as follows:

**Amendments to the Claims** begin on page 2 of this paper.

**Remarks/Arguments** begin on page 4 of this paper.